

**Form 1449 (Modified)****Information Disclosure
Statement By Applicant**

(Use Several Sheets if Necessary)

Atty Docket
No.SUN1P507/P4152Application No.:
09/465,994

Applicant: Ye, et al.

Filing Date 12-16-1999

Group 2121

U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
	A						
	B						

Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation
	C						Yes
	D						No

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
	E	Second Office Action issued July 9, 2004, citing previously-cited documents: EP0524071A1 and EP0908821A1; Chinese Patent Application No. 00810268.6, filed July 13, 2000, Methods and Apparatus For Managing An Application According To an Application Lifecycle.
	F	

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



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Information Disclosure Statement By Applicant				Applicant: Ye, et al.	
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U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
TP	A	6,374,286	04-2002	Gee et al.	709	108	4/6/98
TP	B	6,496,871	12-2002	Jagannathan et al.	709	317	6/30/98
C							
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Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation	
							Yes	No
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L								

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
	M	
	N	
	O	
Examiner	<i>Taplana</i>	Date Considered <i>10/28/04</i>

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